## Abstract Submitted for the MAR14 Meeting of The American Physical Society

Efficient *n*-type doping of zinc-blende III-V semiconductor nanowires<sup>1</sup> LUCAS V. BESTEIRO, LUIS TORTAJADA, J. SOUTO, L.J. GALLEGO, Universidad de Santiago de Compostela, Spain, JAMES R. CHE-LIKOWSKY, The University of Texas at Austin, M.M.G. ALEMANY, Universidad de Santiago de Compostela, Spain — We demonstrate that it is preferable to dope III-V semiconductor nanowires by *n*-type anion substitution as opposed to cation substitution. Specifically, we show the dopability of zinc-blende nanowires is more efficient when the dopants are placed at the anion site as quantified by formation energies and the stabilization of DX-like defect centers. The comparison with previous work on *n*-type III-V semiconductor nanocrystals also allows to determine the role of dimensionality and quantum confinement on doping characteristics of materials. Our results are based on first-principles calculations of InP nanowires by using the PARSEC code.

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